

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	48	"6130129"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L2	48	"6130129"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L3	4314	STI with LOCOS	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L4	112	STI with LOCOS with FOX	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L5	799	STI with LOCOS with field adj oxide	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L6	387	(floating adj gate with etch\$3) and (STI or LOCOS or FOX) with etch\$3 and tunnel adj oxide and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L7	387	(floating adj gate with etch\$3) and ((STI or LOCOS or FOX) with etch\$3) and tunnel adj oxide and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33

L8	217	L7 and (floating adj gate with (sidewall or spacer))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L9	217	L8 and etch\$3 with (STI or FOX or isolation or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L10	31	L8 and etch\$3 with (STI or FOX or isolation or LOCOS) with (recess\$3 or slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L11	30	L8 and etch\$3 with (STI or FOX or isolation or LOCOS) with (recess\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L12	48	"6130129"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L13	48	"6130129"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L14	4314	STI with LOCOS	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L15	112	STI with LOCOS with FOX	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L16	799	STI with LOCOS with field adj oxide	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33

L17	387	(floating adj gate with etch\$3) and (STI or LOCOS or FOX) with etch\$3 and tunnel adj oxide and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L18	387	(floating adj gate with etch\$3) and ((STI or LOCOS or FOX) with etch\$3) and tunnel adj oxide and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L19	217	L18 and (floating adj gate with (sidewall or spacer))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L20	217	L19 and etch\$3 with (STI or FOX or isolation or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L21	31	L19 and etch\$3 with (STI or FOX or isolation or LOCOS) with (recess\$3 or slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L22	30	L19 and etch\$3 with (STI or FOX or isolation or LOCOS) with (recess\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L23	4664	L12 L13 L14 L15 L16 L17 L18 L19 L20 L21 L22	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L24	13981	floating adj gate and (isolation or STI or FOX or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33

L25	4750	L24 and etch\$3 with floating adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L26	2191	L25 and ((sidewall or spacer) with floating adj gate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L27	2040	L26 and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L28	1339	L27 and (recess or trench or via) with (isolation or FOX or STI or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L29	1083	L27 and (recess or trench or via) adj2 (isolation or FOX or STI or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L30	4561	floating adj gate with (isolation or STI or FOX or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L31	2579	L30 and etch\$3 with floating adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L32	1366	L31 and ((sidewall or spacer) with floating adj gate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L33	831	L32 and (recess or trench or via) adj2 (isolation or FOX or STI or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33

L34	73	L33 and etch\$3 with (STI or FOX or isolation or LOCOS) with (recess\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L35	61	L34 and ((second or two) with (isolation or FOX or STI or LOCOS))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L36	6	("20050224860" "6403421" "6743675" "6838342" "6884679" "6911370").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2008/05/01 20:33
L37	3140	438/257.ccls.	US-PGPUB; USPAT; USOCR	OR	ON	2008/05/01 20:33
L38	46	L35 and ((conductive or polysilicon) with (sidewall or spacer))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L39	34	L35 and ((conductive or polysilicon) with (sidewall or spacer)) with floating adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L40	791	438/259.ccls.	US-PGPUB; USPAT; USOCR	OR	ON	2008/05/01 20:33
L41	19207	L1 L2 L3 L4 L5 L6 L7 L8 L9 L10 L11 L12 L13 L14 L15 L16 L17 L18 L19 L20 L21 L22 L23 L24 L25 L26 L27 L28 L29 L30 L31 L32 L33 L34 L35 L36 L37 L38 L39 L40	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:33
L42	84	37 and etch\$3 with (STI or FOX or isolation or LOCOS) with (recess\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:35

L43	126	40 and ((conductive or polysilicon) with (sidewall or spacer)) with floating adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:36
L44	71	42 and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:36
L45	124	43 and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:36
L46	124	45 and ((conductive or polysilicon) with (sidewall or spacer)) with floating adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:46
L47	24	45 and ((conductive or polysilicon) adj (sidewall or spacer)) with floating adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:46
L48	25	45 and (extend\$3 with (sidewall or spacer)) with floating adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/01 20:52
S1	40	"6130129"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/28 22:13
S2	44	"6130129"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/12 20:52
S3	4013	STI with LOCOS	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/12 20:53

S4	103	STI with LOCOS with FOX	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/12 20:53
S5	753	STI with LOCOS with field adj oxide	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/11/12 20:55
S6	383	(floating adj gate with etch\$3) and (STI or LOCOS or FOX) with etch\$3 and tunnel adj oxide and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/15 15:06
S7	383	(floating adj gate with etch\$3) and ((STI or LOCOS or FOX) with etch\$3) and tunnel adj oxide and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/15 15:06
S8	213	S7 and (floating adj gate with (sidewall or spacer))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/15 15:07
S9	213	S8 and etch\$3 with (STI or FOX or isolation or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/15 15:43
S10	31	S8 and etch\$3 with (STI or FOX or isolation or LOCOS) with (recess\$3 or slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/15 15:43
S11	30	S8 and etch\$3 with (STI or FOX or isolation or LOCOS) with (recess\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/15 15:49

S12	48	"6130129"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45
S13	48	"6130129"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45
S14	4308	STI with LOCOS	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45
S15	112	STI with LOCOS with FOX	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45
S16	798	STI with LOCOS with field adj oxide	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45
S17	387	(floating adj gate with etch\$3) and (STI or LOCOS or FOX) with etch\$3 and tunnel adj oxide and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45
S18	387	(floating adj gate with etch\$3) and ((STI or LOCOS or FOX) with etch\$3) and tunnel adj oxide and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45
S19	217	S18 and (floating adj gate with (sidewall or spacer))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45
S20	217	S19 and etch\$3 with (STI or FOX or isolation or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45

S21	31	S19 and etch\$3 with (STI or FOX or isolation or LOCOS) with (recess\$3 or slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45
S22	30	S19 and etch\$3 with (STI or FOX or isolation or LOCOS) with (recess\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45
S23	4658	S12 S13 S14 S15 S16 S17 S18 S19 S20 S21 S22	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:45
S24	13963	floating adj gate and (isolation or STI or FOX or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:48
S25	4745	S24 and etch\$3 with floating adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:48
S26	2188	S25 and ((sidewall or spacer) with floating adj gate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:49
S27	2037	S26 and control adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:49
S28	1336	S27 and (recess or trench or via) with (isolation or FOX or STI or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:50
S29	1081	S27 and (recess or trench or via) adj2 (isolation or FOX or STI or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:50

S30	4555	floating adj gate with (isolation or STI or FOX or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:51
S31	2576	S30 and etch\$3 with floating adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:51
S32	1364	S31 and ((sidewall or spacer) with floating adj gate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:51
S33	829	S32 and (recess or trench or via) adj2 (isolation or FOX or STI or LOCOS)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:51
S34	72	S33 and etch\$3 with (STI or FOX or isolation or LOCOS) with (recess\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:52
S35	60	S34 and ((second or two) with (isolation or FOX or STI or LOCOS))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 19:57
S36	6	("20050224860" "6403421" "6743675" "6838342" "6884679" "6911370").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2008/04/29 20:16
S37	3137	438/257.ccls.	US-PGPUB; USPAT; USOCR	OR	ON	2008/04/29 21:34
S38	45	S35 and ((conductive or polysilicon) with (sidewall or spacer))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 21:34

S39	33	S35 and ((conductive or polysilicon) with (sidewall or spacer)) with floating adj gate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/04/29 21:38
S40	791	438/259.ccls.	US-PGPUB; USPAT; USOCR	OR	ON	2008/04/29 22:34

5/1/08 9:12:11 PM

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